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Article

12kW@2K Helium Cryogenic Control System Design

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Abstract

This paper presents the design and implementation of a 12kW@2K supercritical helium cryogenic control system for the Shanghai Hard X-ray Free Electron Laser Facility (SHINE). The system provides a stable cryogenic environment for 56 standard 1.3 GHz superconducting modules, meeting the stringent temperature control requirements of the accelerator for high-precision operation of superconducting cavities. A distributed PLC architecture integrated with EPICS is adopted, comprising three refrigerators, four distribution valve boxes, and 39 module subsystems. Redundant network design ensures reliable data transmission. Core functionalities include a four-stage automated cooling process (from 300 K to 2 K), dynamic power compensation, and a safety interlock mechanism. Experiments show that the system can stabilize the liquid level of the helium tank within $\pm 1\%$ and maintain the pressure at $3100\text{Pa} \pm 10\text{Pa}$, effectively ensuring the smooth progress of low-level experiments. Dynamic power compensation adjusts heater power in real time based on a model correlating cavity pressure with heat load, ensuring stability during cryogenic operation. The system has been successfully applied in the commissioning of the injector section, validating its efficiency and safety in providing a cryogenic environment for superconducting accelerators, and serving as a key technical foundation for the SHINE project.

Keywords: autonomous control; cryogenic control; PLC; EPICS; hard-X-ray free-electron laser

1. Introduction

The Shanghai Hard X-ray Free Electron Laser Facility (SHINE) is a high-repetition-rate hard X-ray free electron laser facility capable of producing X-ray pulses at a maximum repetition rate of 1 MHz. With a designed electron beam energy of 8 GeV, SHINE has extensive applications in physics, chemistry, materials science, life sciences, and other fields. The facility currently includes three undulator beamlines, with a total length of approximately 2 km from the injector to the end of the undulator. SHINE will utilize 400 superconducting cavities to provide energy for the electron beam, with a designed accelerating gradient of 20 MV/m and a quality factor of 2.7×10^{10} under continuous-wave operation. A total of 50 superconducting accelerating modules operating at 1.3 GHz are required, with two additional 3.9 GHz superconducting modules for bunch compression. These modules are connected in series to form four superconducting accelerator sections: L1, L2, L3, and L4. According to the latest design, L1 consists of 4 modules, L2 of 18 modules, L3 of 6 modules, and L4 of 24 modules. A schematic diagram of the SHINE device is shown in Figure 1. please refer to [1].

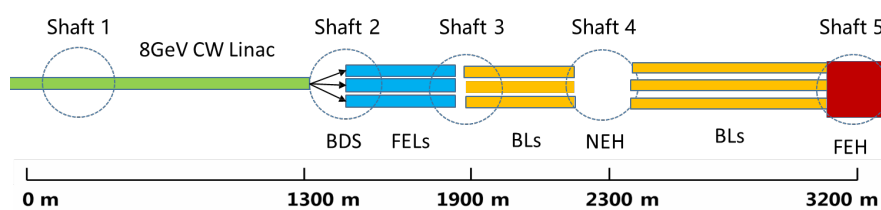


Figure 1. Overall schematic diagram of the SHINE device.

To meet the overall requirements of the accelerator, the SHINE 12 kW@2 K helium cryogenic system provides the necessary cryogenic environment for the superconducting linear accelerator. Two cryogenic plants are installed at both ends of the linear accelerator to address cooling, warm-up, rapid cooling, and operational needs under different circuit conditions. The SHINE cryogenic system includes a 12 kW@2 K refrigeration system, consisting of three helium refrigerators (4 kW@2 K each), four distribution valve boxes, 1.2 km of cryogenic transfer lines, a 64,000 m³ helium storage system, three purification and recovery systems, two liquid nitrogen systems, and supporting vacuum and control systems. The cryogenic plants provide three cooling capacities: 12 kW@2 K, 4.5 kW@4.5–8 K, and 45 kW@35–55 K. For 2K, a cold compressor needs to be used for extraction. These cooling capacities are generated by helium cryogenic refrigerators and delivered to the superconducting linear accelerator via the distribution and transfer system. The design indicators of a single cryogenic system are summarized in Table 1.

Table 1. Margin specifications.

Parameter	Line	Pressure(bar)	Temperature(K)	Cooling Capacity(kW)	Flow Rate(g/s)
2K Loop	A	3	4.5	4kW@2K	188
	B	0.026	3.8		
Intermediate Shield Loop	C	3	4.5	1.5kW@4.52K	37.2
	D	2	8		
Thermal Shield Loop	E	5.5	35	15kW@40K	143.1
	F	4.5	35		

As the largest cryogenic superconductivity platform in China and even in Asia, based on the provision of sufficient cold sources by a large number of refrigeration-related equipment, the reliability and accuracy of its operation mainly rely on the low-temperature measurement and control system. Therefore, before the official project construction, a 1kW@2K low-temperature test platform was built for operation and maintenance, which was used to explore, evaluate and verify various key low-temperature measurement and control technologies. Through this process, the following main achievements were achieved:

- Precise and reliable measurement and control of various low-temperature-related sensors and actuators;
- The overall architecture of the measurement and control for the large low-temperature platform, such as communication, software and hardware, was determined;
- The core controllers and other components were determined through iterative evaluation. Compared with the 1kW@2K test platform, the 12kW@2K system has significantly improved in terms of volume, equipment distribution distance, liquid helium pressure, flow rate, automation of temperature rise and drop, and other core parameters. The following mainly conducts relevant research and discussions based on the current debugging and operation situation [2,3].

2. Design of SHINE Cryogenic Control System

2.1. Layout of Cryogenic System

The 12 kW@2 K cryogenic system is designed to meet the cooling requirements of superconducting cavity modules and superconducting undulators for the SHINE hard X-ray free electron laser facility. The system comprises refrigerators, distribution valve boxes, vacuum and liquid nitrogen subsystems, and module systems. Each subsystem has a dedicated control system to achieve its specific control objectives. The cryogenic control system includes three helium refrigerator control systems from Air Liquide, one VBx80000 injection valve box control system, one VBx81000 distribution valve box control system, one VBx82000 distribution valve box control system, one VBx83000 distribution valve box control system, two vacuum and liquid nitrogen control systems, and 69 cryogenic module control systems. These 46 PLC-based control subsystems are distributed across two shafts (referred to as Shaft 1 and Shaft 2) and the tunnel. The equipment layout is illustrated in Figure 2.

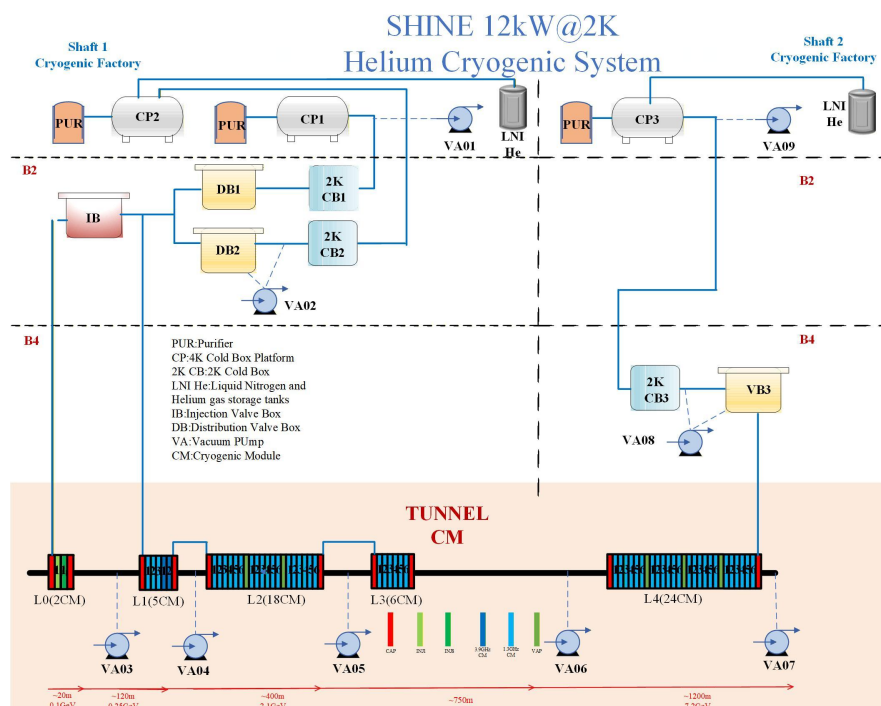


Figure 2. SHINE 12kW@2K Schematic Diagram of the Helium Cryogenic System.

Considering the characteristics of low-temperature equipment and the independent control requirements of each subsystem, each subsystem in the equipment control layer is equipped with a set of PLC control system. The PLC programs and human-machine interface (HMI) are developed using the latest TIA Portal Unified. Unified is a modernized automation development platform that integrates PLC programming, HMI design, and network configuration. It has advantages such as efficiency, integration, standardization, and intelligence, making it suitable for the development of complex industrial automation systems in low-temperature factories. The specific implementation is as follows: The functions of each subsystem in the equipment control layer are independently connected through Ethernet and Profinet. The upper layer uses TIA Portal Unified to develop the WEB control interface for each subsystem to achieve the required human-machine interaction, debugging, and operation in the cryogenic factory. At the same time, it has a set of EPICS system to provide human-machine interface and other functions for the modules. The list of all subsystems is shown in Table 2:

Table 2. List of each subsystem for cryogenic control.

Name	Location	PLC Quantity
VB80000 Injection Valve Box Control	Shaft 1	1
VB81000 Distribution Valve Box Control	Shaft 1	1
VB82000 Distribution Valve Box Control	Shaft 1	1
VB83000 Distribution Valve Box Control	Shaft 2	1
Interlock Control	Shaft 2	1
Vacuum Liquid Nitrogen Control	Shaft 1	1
Vacuum Liquid Nitrogen Control	Shaft 2	1
Superconducting Module Control	Tunnel	69

2.2. Network Architecture of Cryogenic Control System

The overall control architecture diagram of the 12kW@2K low-temperature control system is shown in Figure 3. It is necessary to achieve the requirements of rapidity, stability and accuracy for data acquisition and control. Since the low-temperature debugging process is a slow process with low real-time requirements, the network design adopts a combination of mature and reliable

commercial networks and PLC real-time networks. At the same time, in the network architecture, the core switch and access switch are set with redundancy at key positions based on actual location and layout characteristics. This can not only improve reliability but also simplify the network architecture. The specific implementation of the network is as follows: The access switch connected to the core switch of Shaft 1 and Shaft 2 connects the OPI/WinCC, Monitor PC, Archive Server, Alarm Server, Gateway Server, and remote online control center Central Control System for upper-level control equipment, responsible for data interconnection and communication between Shaft 1 and Shaft 2 and remote data acquisition, control and alarm of all low-temperature related equipment in the control room; The outdoor liquid nitrogen and helium gas storage tank station connected to the access switch 1 of Shaft 1, 2 pure purification recovery PLCs, 2 vacuum stations and touch screens form a system; The liquid nitrogen vacuum PLC, helium refrigeration PLC, 3 valve box control PLC, 2 vacuum stations and corresponding equipment touch screens connected to the access switch 2 of Shaft 1; One set of modular control PLC connected to the tunnel access switch 3; Three sets of modular control PLC connected to the tunnel access switch 4; Nine sets of modular control PLC connected to the tunnel access switch 5; Three sets of modular control PLC connected to the tunnel access switch 6; Twelve sets of modular control PLC connected to the tunnel access switch 7; One set of liquid nitrogen vacuum control PLC and one set of helium refrigeration control PLC connected to the access switch 8 of Shaft 2, and one valve box control PLC; One vacuum from station PLC, one recovery purification control PLC, one outdoor liquid nitrogen and helium gas storage tank PLC and corresponding touch screens connected to the access switch 9 of Shaft 2 form a system. These PLCs are responsible for data acquisition, local control, display of local human-machine interface and remote control of various on-site low-temperature equipment in different areas including Shaft 1, Shaft 2, tunnel, and outdoor tank area. At the same time, each PLC is connected to a set of IOC controller to complete functions such as EPICS control, data acquisition, storage, historical data acquisition and curve graph acquisition.

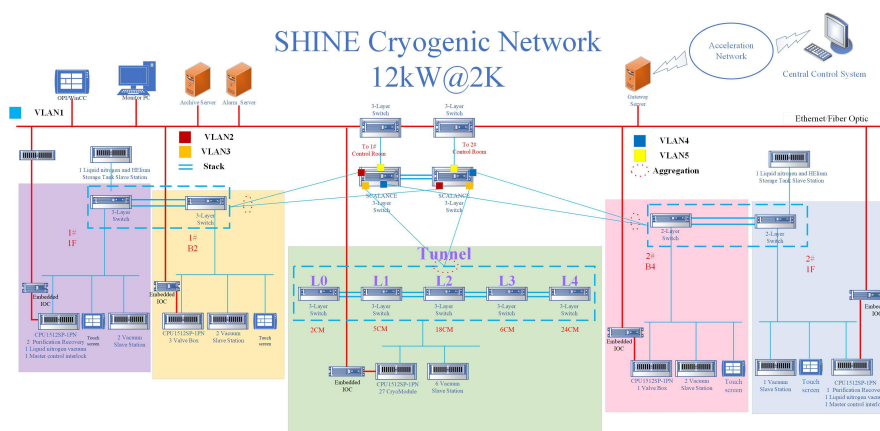


Figure 3. 12kW@2K Overall schematic diagram of the cryogenic control system.

12kW@2K Schematic diagram of the overall control architecture of the low temperature control system Including the core layer switch 1 of Shaft 1, the core layer switch 2 of Shaft 2, the access switch 1 of Shaft 1, the access switch 2 of Shaft 1, the access switches 3 to 7 in the tunnel, the access switch 8 of Shaft 2, the access switch 9 of Shaft 2, as Shaft as the access switches 10 and 11 connected to the control console host of Shaft 1 and Shaft 2 respectively; Among them, the two cores configured are 10-gigabit switches that can be iStack stacked through 10GB 10-gigabit ports. When either core has a circuit failure or a link failure, it will not affect the interconnection and intercommunication of the services in the two Shafts. They are respectively placed in the cabinets of Shaft 1/2 and can be connected to both UPS and mains power in a dual power configuration, which maximizes their safety and reliability. The access layer is responsible for data exchange within the same Shaft. The access layer system enhances the reliability at the device level through redundant backup among multiple member devices. Through the cross-device link aggregation function, the reliability of the link is improved. When any access switch fails, it does not affect the service intercommunication of devices under other

switches within the same Shaft. Different Shafts are divided into virtual local area networks, and different areas are divided into multiple logically independent parts to improve the security of the network. The creation of vlans in different areas, port division and intercommunication between vlans are achieved through VLAN configuration. Meanwhile, the corresponding spanning tree protocol (STP/RSTP/MSTP) configuration is carried out according to the network topology and requirements, which can avoid loops in the network and ensure the normal transmission of data in the network. And configure the DHCP Snooping function on the switch. Correspondingly, configure the legitimate DHCP server ports as trust interfaces to filter out illegal DHCP servers. Later, if the devices within the network need to be monitored, remote monitoring and management of the switch can be achieved by configuring the Simple Network Management Protocol (SNMP). Meanwhile, by taking advantage of the SNMP v1/v2/v3 functions of the switch and the rich Management Information Base (MIB), it is convenient to integrate into the network management system for monitoring and troubleshooting.

12kW@2K Schematic diagram of the overall network architecture of the low temperature control system is shown in Figure 4. Including the core layer switch 1 of Shaft 1, the core layer switch 2 of Shaft 2, the access switch 1 of Shaft 1, the access switch 2 of Shaft 1, the access switches 3 to 7 in the tunnel, the access switch 8 of Shaft 2, the access switch 9 of Shaft 2, as Shaft as the access switches 10 and 11 connected to the control console host of Shaft 1 and Shaft 2 respectively; Among them, the two cores configured are 10-gigabit switches that can be iStack stacked through 10GB 10-gigabit ports. When either core has a circuit failure or a link failure, it will not affect the interconnection and intercommunication of the services in the two Shafts. They are respectively placed in the cabinets of Shaft 1/2 and can be connected to both UPS and mains power in a dual power configuration, which maximizes their safety and reliability. The access layer is responsible for data exchange within the same Shaft. The access layer system enhances the reliability at the device level through redundant backup among multiple member devices. Through the cross-device link aggregation function, the reliability of the link is improved. When any access switch fails, it does not affect the service intercommunication of devices under other switches within the same Shaft. Different Shafts are divided into virtual local area networks, and different areas are divided into multiple logically independent parts to improve the security of the network. The creation of vlans in different areas, port division and intercommunication between vlans are achieved through VLAN configuration.

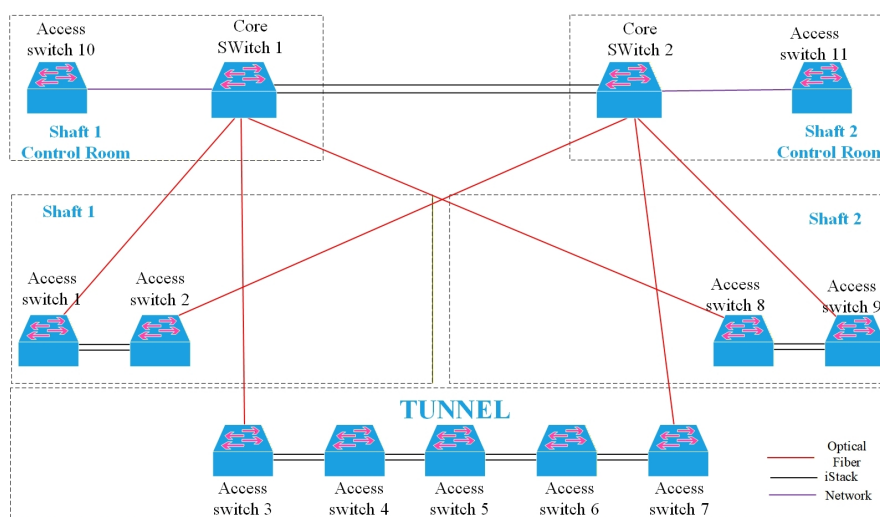


Figure 4. 12kW@2K cryogenic control system overall network architecture diagram.

2.3. Automatic Cooling Process

The cooling process for the superconducting modules is divided into four stages based on the accelerator's requirements:

- Stage 1 (300 K–160 K): Conventional cooling using a mixture of 300 K and 35 K helium. Safety thresholds include a radial temperature difference ≤ 15 K in Tank B and an axial temperature

difference ≤ 50 K in Tube B, with a vacuum level $\leq 1.0E - 2$ Pa and a thermal vacuum interlock at 10 Pa;

- Stage 2 (160 K–45 K): Hydrogen poisoning zone. The cooling rate is controlled at 10–20 K/h, preferably around 15 K/h, with a total duration ≤ 12 h. During the hydrogen poisoning phase (150 K–70 K), the cooling duration is limited to 8 h, maintaining a radial temperature difference ≤ 15 K and axial temperature difference ≤ 50 K in Tube B;
- Stage 3 (45 K–4.5 K): Rapid cooling using 4.5 K helium. The cooling rate is controlled at 10 K/min or 30 g/s. After rapid cooling, each module is maintained at 1 g/s flow to stabilize at 4.5 K;
- Stage 4 (4.5 K–2 K): Pressure reduction cooling to achieve the 2 K superconducting state for experimental operation.

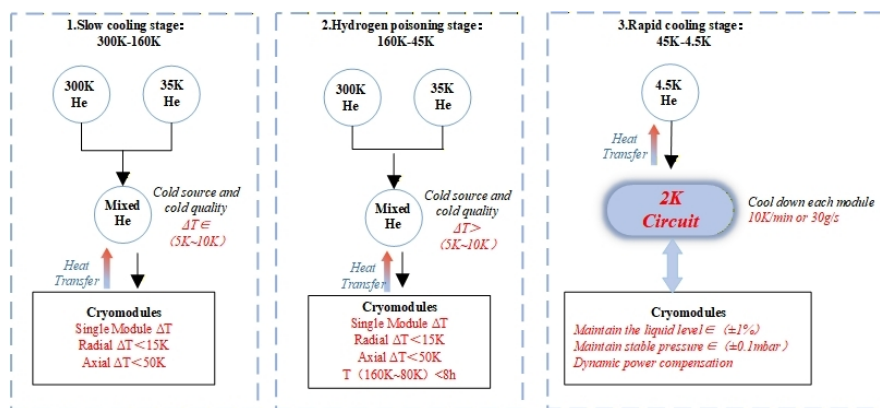


Figure 5. Schematic diagram of cooling modes at each stage.

The SHINE cryogenic system successfully implements automatic cooling in all stages. For example, the AB line automatic cooling process from 160 K to 45 K in the injector section is described as follows. The injector section includes a single-cavity module and an eight-cavity module, supported by the first helium refrigerator (CP1), 2 K cold box (CB1), distribution valve box (DB1, VBx81000), and injection valve box (IB, VBx80000). The simplified flow diagram of the injector section is shown in Figure 6. Such as the superconducting cavity's characteristic temperature (T_{hv} , T_{br}), radial and axial temperature differences (T_{ba}), and the temperatures and pressures of the distribution valve box (TE81130, PT81140, PT81250) to control the mixing and uniformity of helium gas in the pipelines. This stage primarily involves adjusting the valves CV81810 (300 K helium line) and CV81710 (35 K helium line) in the injection valve box. After completing this stage, the system transitions to the 45 K stabilization phase and subsequent 45 K–2 K cooling stages.

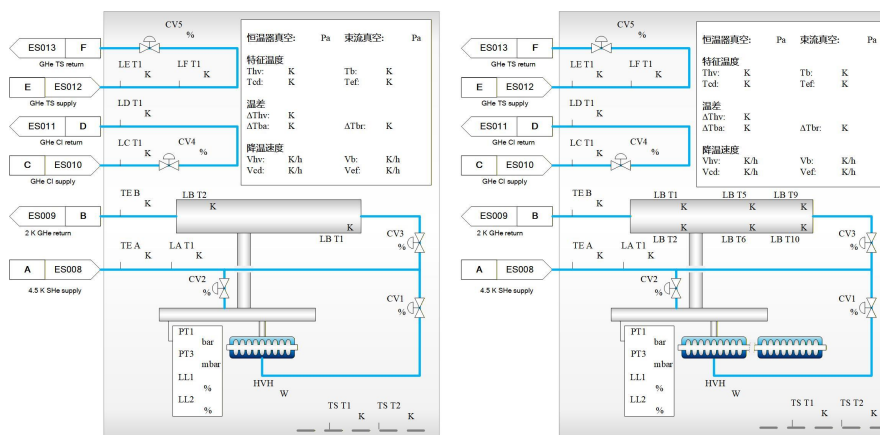
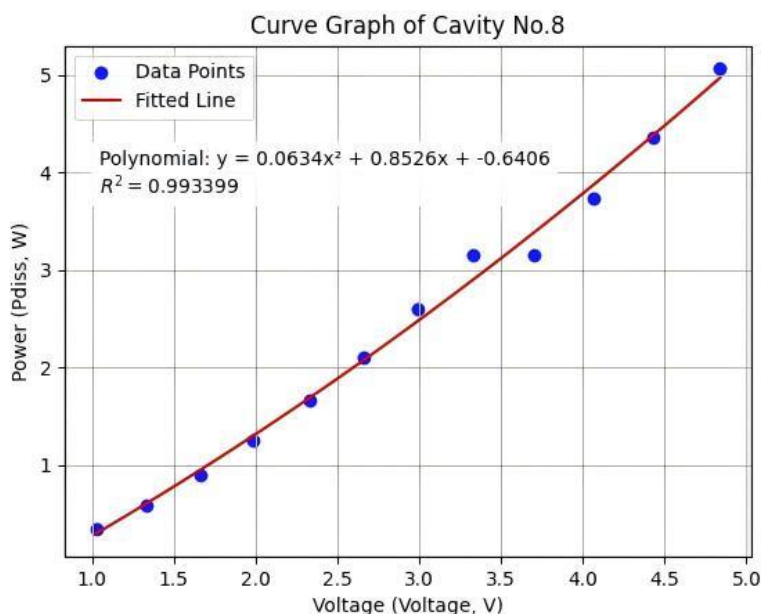


Figure 6. Simple flow diagram of the injector section.

Table 4. Inject the cavity pressure and cavity consumption data of Cavity 8 of the eighth cavity.

	Cavity Voltage(V)	Pdiss(W)
1	1.023220486	0.342239325
2	1.334997106	0.592865608
3	1.664134838	0.897569204
4	1.984953704	1.25327587
5	2.334707755	1.659393987
6	2.662398727	2.110436411
7	2.98864294	2.605574227
8	3.331163194	3.147402664
9	3.698278356	3.148961412
10	4.067563657	3.734590039
11	4.425636574	4.365135565
12	4.839771412	5.06258134

The final curve graph obtained through the fitting of cavity pressure and cavity loss is shown in Figure 8:

**Figure 8.** Cavity loss curve graph.

$$y = 0.06x^2 + 0.85x - 0.64 \quad (3)$$

The effective control of heater power plays a critical role in dynamic power compensation. The control flow diagram for the TDK heater power in the injector section is shown in Figure 9, with two modes: local control and remote control.

- Local Control Mode: When set to local control, power output is manually adjusted via the power supply's control panel;
- Remote Control Mode: Primarily used during experiments, this mode requires inputting each heater's resistance value. Power is enabled only if no interlocks are triggered. After enabling, the power control method is divided into three stages: heater normal operation mode, superconducting cavity heater auto-compensation mode, and liquid level heater PID mode.

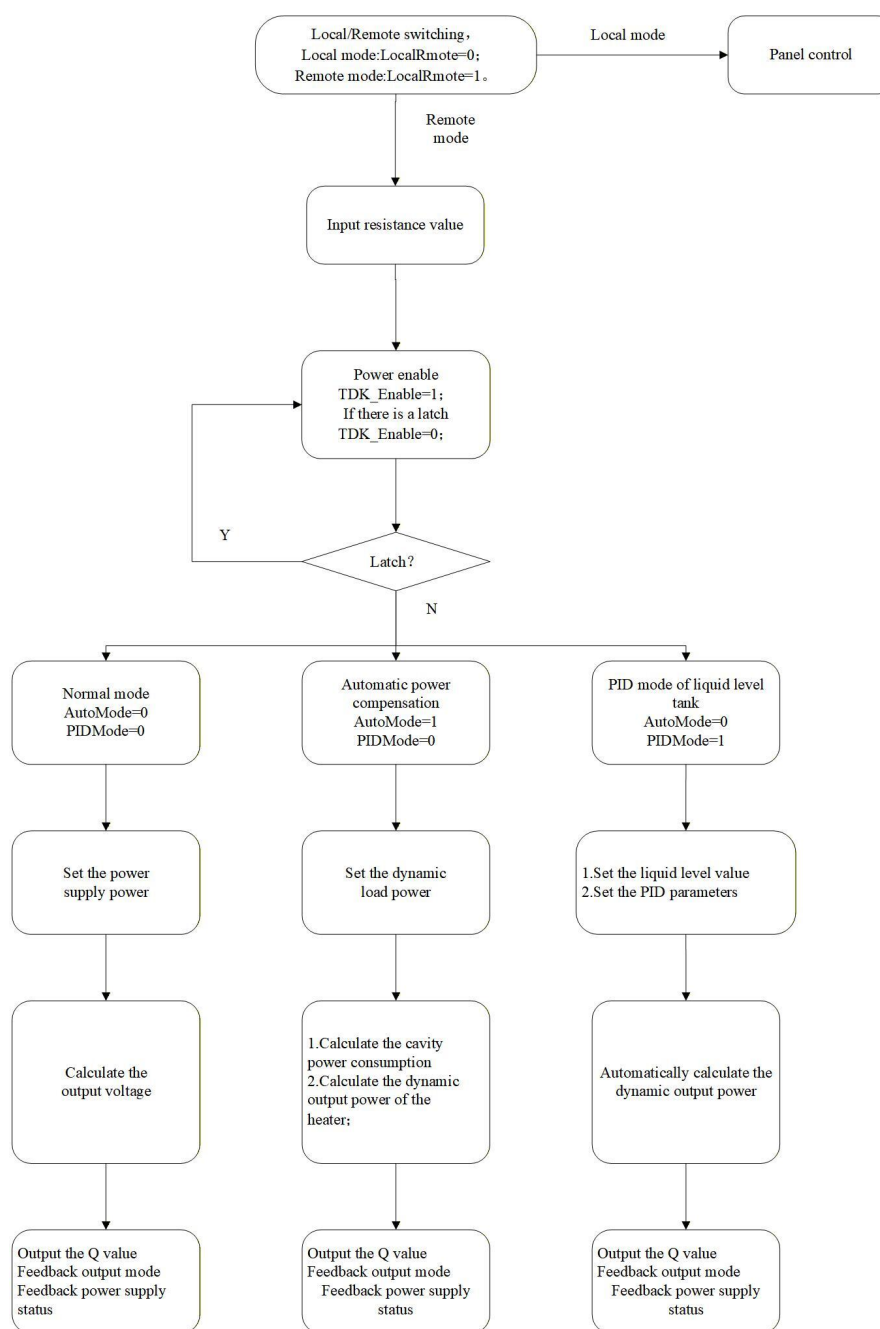


Figure 9. Power control flow chart of TDK for injector section heater.

3. Commissioning and Operation of Cryogenic System

3.1. Automatic Cooling Experiment

The module cooling process from 300 K to 2 K is divided into stages, with partial control interfaces shown :

- 300K–35K: Mixed helium cools the cold shield, helium container, and superconducting cavity to 80 K, ensuring uniform cooling;
- 45K–4.5K: Liquid helium flow >30 g/s for uniform cooling;
- 4.5K–2K: J-T valve and cryopump control rapid uniform cooling to 2 K, maintaining liquid level stability. From November 24 to December 20, 2024, the injector section underwent a new round of superconducting cavity cooling tests. Automatic valve adjustment based on pressure and temperature achieved reliable cooling. The 300–45 K automatic cooling process met module

requirements, with the complete cooling curve shown in Figure 10. The entire process took approximately 42 hours, with a smooth curve validating the system's effectiveness.

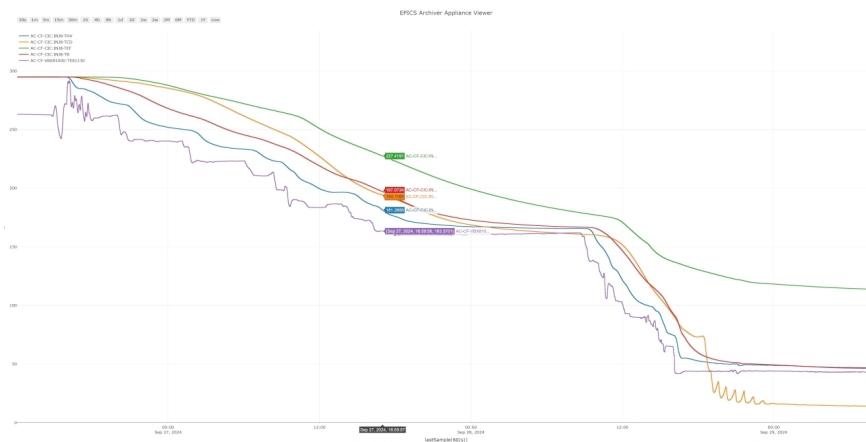


Figure 10. The entire cooling and complete cooling curve.

3.2. 2K liquid Level Stability

After automatic cooling and liquid accumulation, the module's JT valve PID control and superconducting cavity dynamic power compensation were activated to stabilize the helium bath pressure and level. The PID control interfaces for the single-cavity INJ1_FCV2 and eight-cavity INJ8_FCV2 valves are shown in Figure 11.



Figure 11. Valve PID control interface.

Liquid level stability is achieved through real-time level meter data, with closed-loop feedback controlling multiple valves and heater power. The level meter signal is filtered to obtain accurate data, and multivariable coupled PID algorithms adjust valves and heaters to maintain a $\pm 1\%$ stability. High-frequency low-level system data can also be used as criteria. To prevent damage from low levels, interlock alarms are triggered when thresholds are exceeded. The liquid level for the single-cavity module was maintained at 72–74%, and the eight-cavity module at 70–72%, as shown in Figure 12.

Pressure stability is achieved through multiple precision temperature control units. High-frequency cavity pressure data is fitted to calculate cavity loss power (fitting time ≤ 100 ms). PID regulation of high-precision power output maintains a constant total power load, achieving 3100 Pa ± 10 Pa stability. The single-cavity pressure fluctuation was maintained at 31.7–31.9 mbar, and the eight-cavity pressure at 31.6–31.8 mbar.

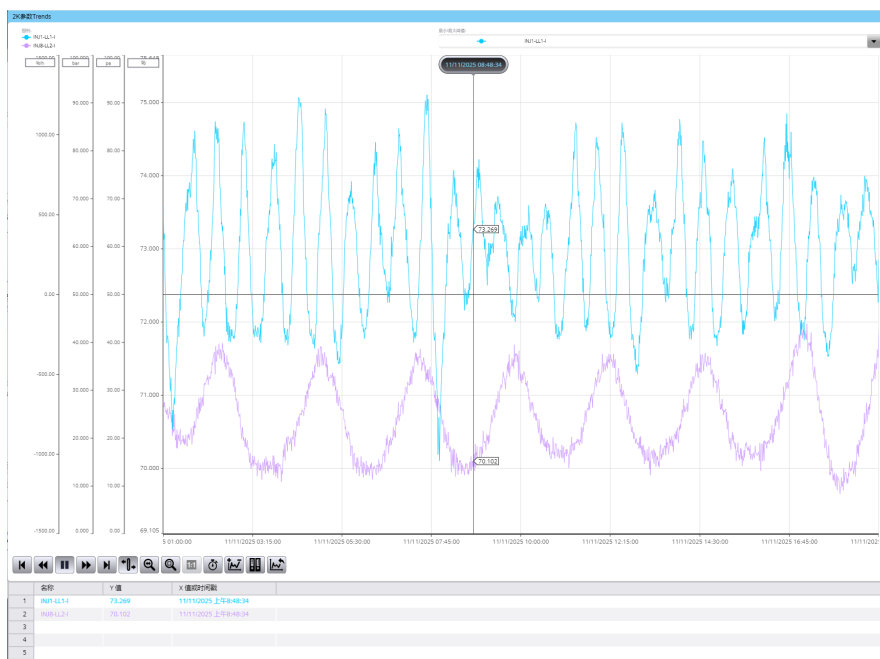


Figure 12. Liquid level stability curve.

3.3. Dynamic Power Compensation Experiment

Dynamic power compensation converts cavity pressure signals into cavity loss data using a derived formula. The total dynamic load is set, and heater output power is adjusted in real time to maintain a constant module load. When the superconducting cavity dynamic power compensation mode is activated, the dynamic total load is set, cavity loss is calculated, and heater power is adjusted accordingly. The process is controlled via PLC, with feedback voltage, current, and power monitored. The single-cavity and eight-cavity module layouts are shown in Figure 13.

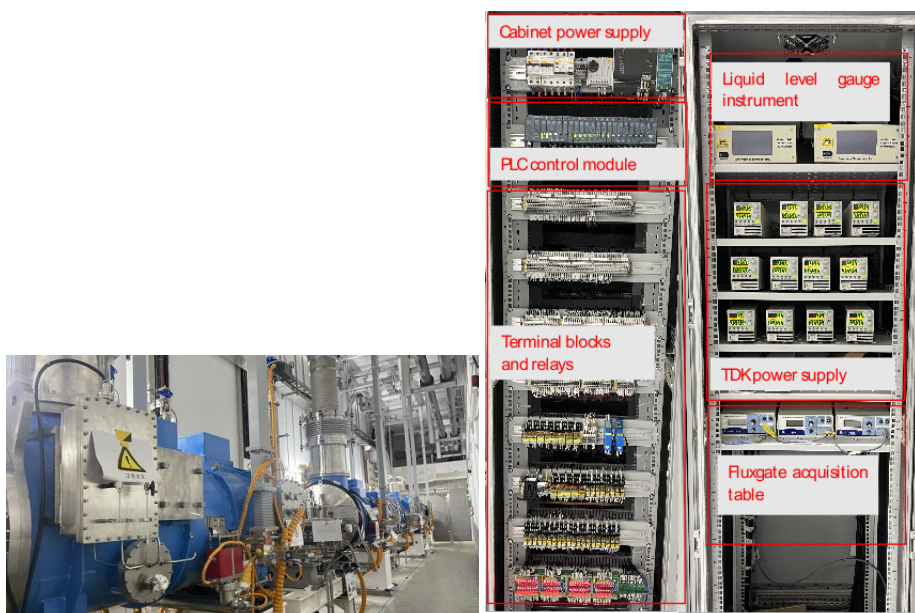


Figure 13. Inject single-chamber and eight-chamber solid and cabinet layout diagrams.



Figure 14. Dynamic power compensation experiments.

4. Conclusions

This paper elaborates on the overall design and implementation of the SHINE cryogenic control system. By integrating open-source EPICS control with PLC systems, the system efficiently achieves cryogenic network construction, automated cooling process control, cryogenic environment safety interlock alarms, and stability in 2 K liquid level, pressure, and dynamic power compensation. Multiple rounds of superconducting cavity cooling, aging, and commissioning experiments conducted in August and December 2024 validated the system's ability to ensure stability, significantly reducing quench frequency during experiments and enhancing the stability and efficiency of accelerator operations.

The SHINE 12 kW@2 K cryogenic control system, through the integration of PLC and EPICS technologies, achieves high-precision management of the superconducting accelerator's cryogenic environment. The four-stage automated cooling process and dynamic power compensation algorithm effectively address issues such as liquid level and pressure fluctuations and quenches at 2 K. Experimental data show a liquid level stability of $\pm 1\%$ and pressure fluctuations within 10 Pa, significantly improving accelerator efficiency. The safety interlock mechanism, incorporating leak, temperature, and oxygen concentration monitoring, ensures equipment and personnel safety. The successful implementation of this system not only meets the technical requirements of the SHINE project but also provides a reusable solution for large-scale scientific facilities, advancing the engineering application of superconducting accelerator cryogenic technology. Future work will focus on optimizing algorithm response speed and exploring more efficient energy-saving control strategies.

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